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## METHOD OF PRODUCING NITRIDE-BASED HETEROSTRUCTURE DEVICES

## ABSTRACT OF THE DISCLOSURE

A method of producing nitride based heterostructure devices by using a quaternary layer comprised of AlInGaN. The quaternary layer may be used in conjunction with a ternary layer in varying thicknesses and compositions that independently adjust polarization charges and band offsets for device structure optimization by using strain compensation profiles. The profiles can be adjusted by altering profiles of molar fractions of In and Al.